

Figure 1: prior art

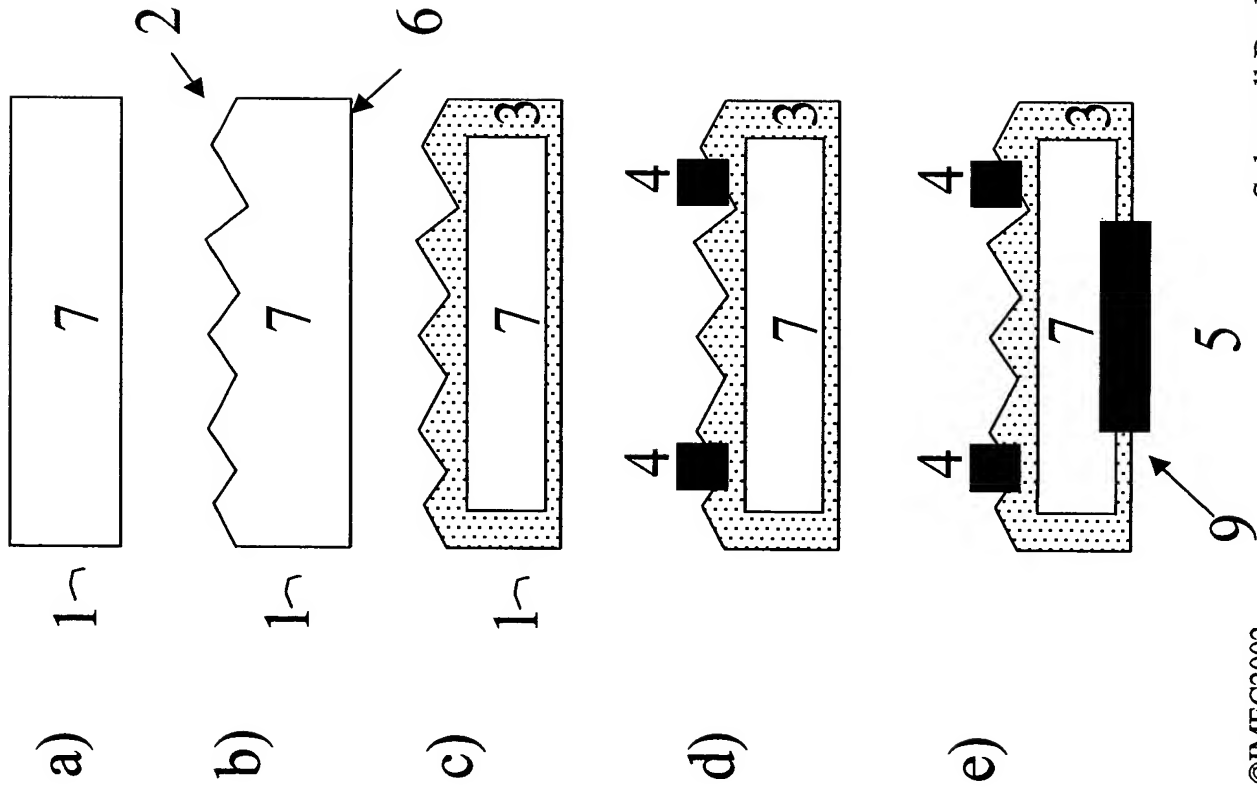


Figure 2: prior art

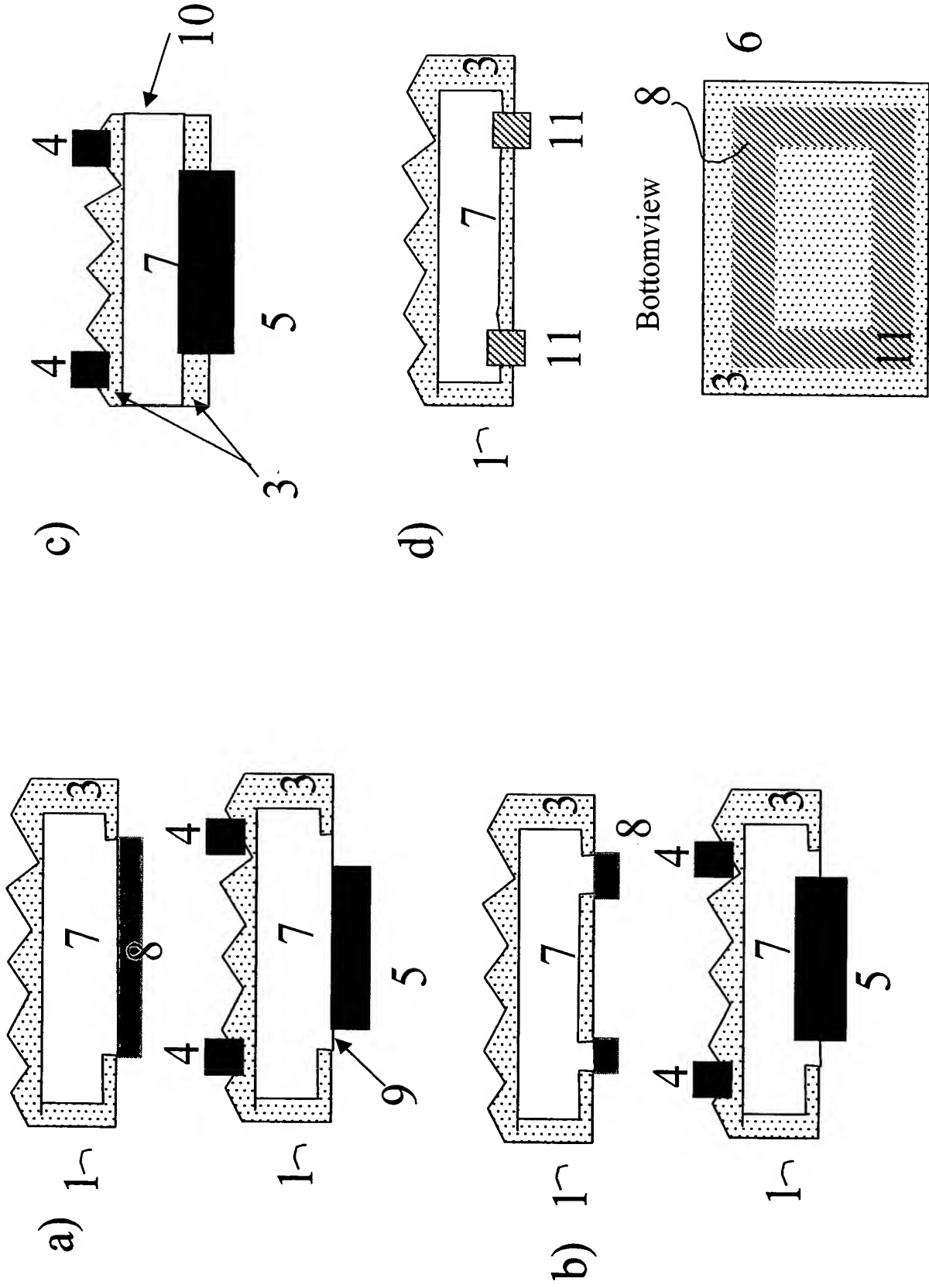


Figure 3:

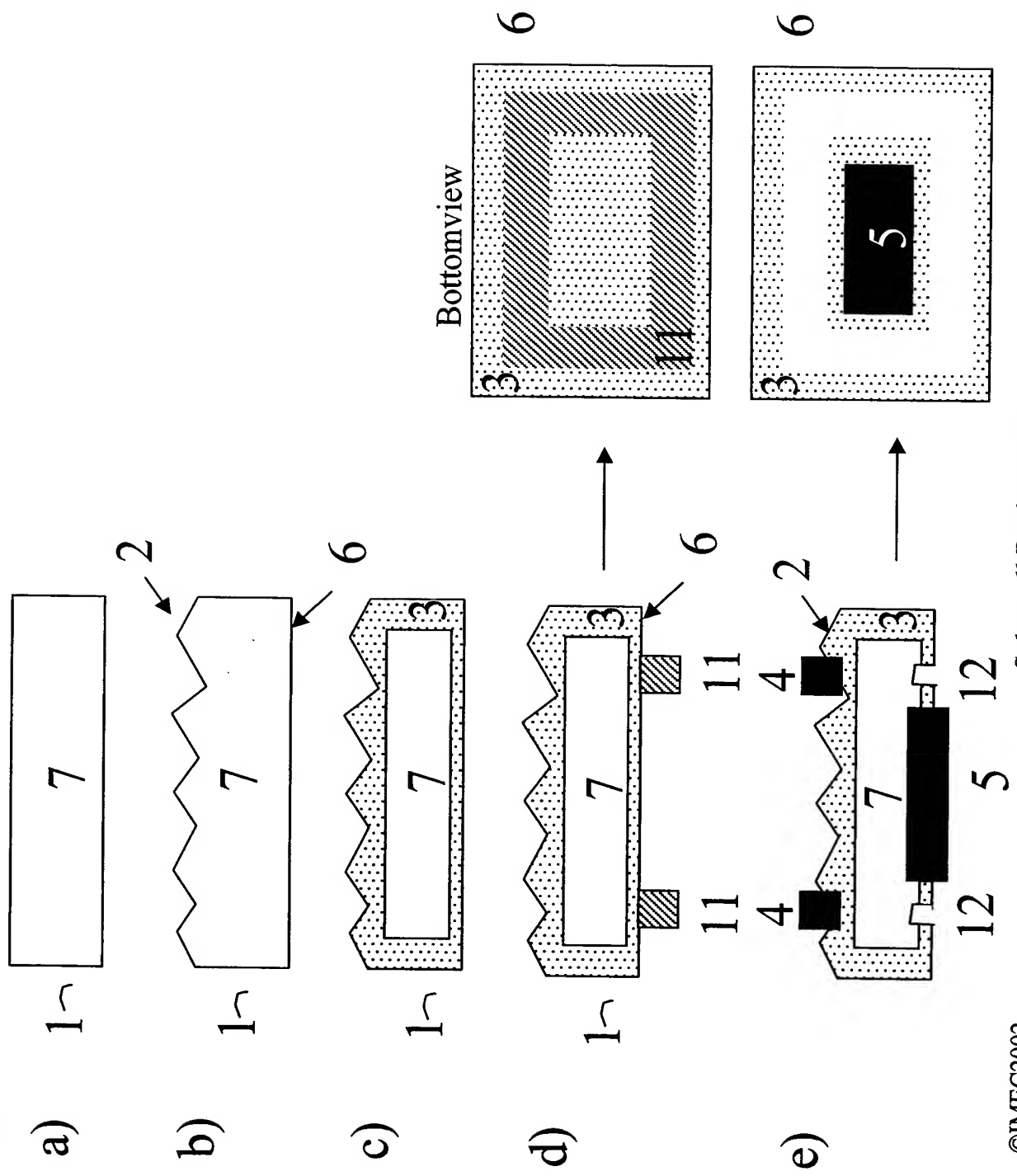


Figure 3:

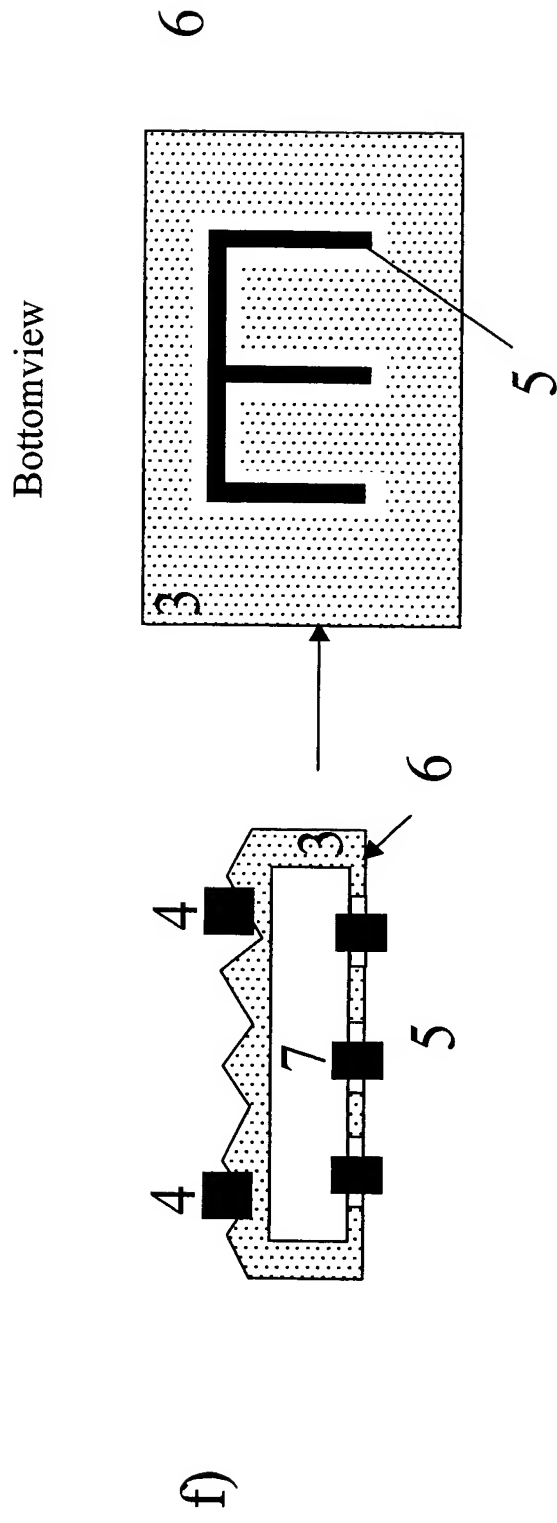


Figure 4:

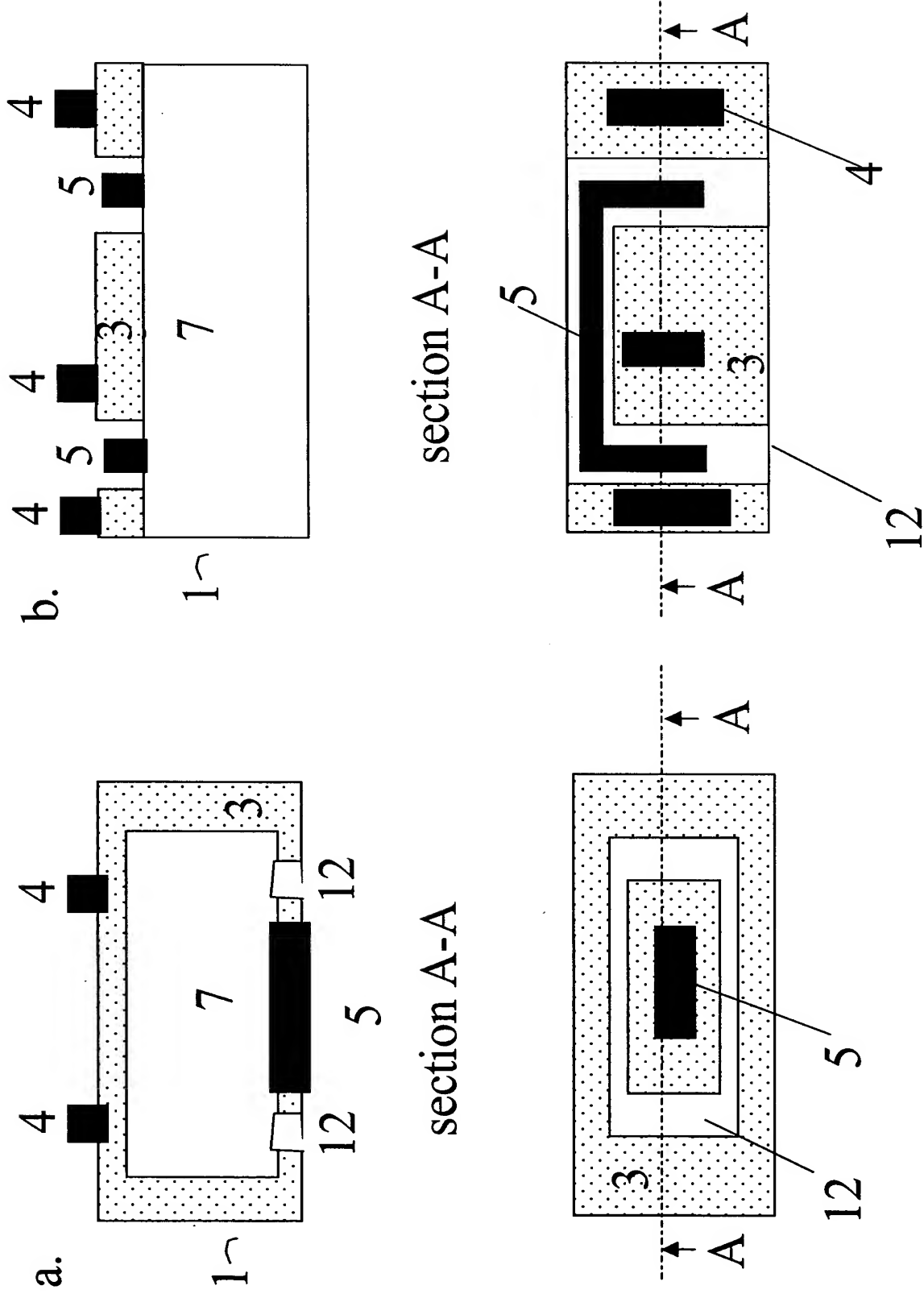
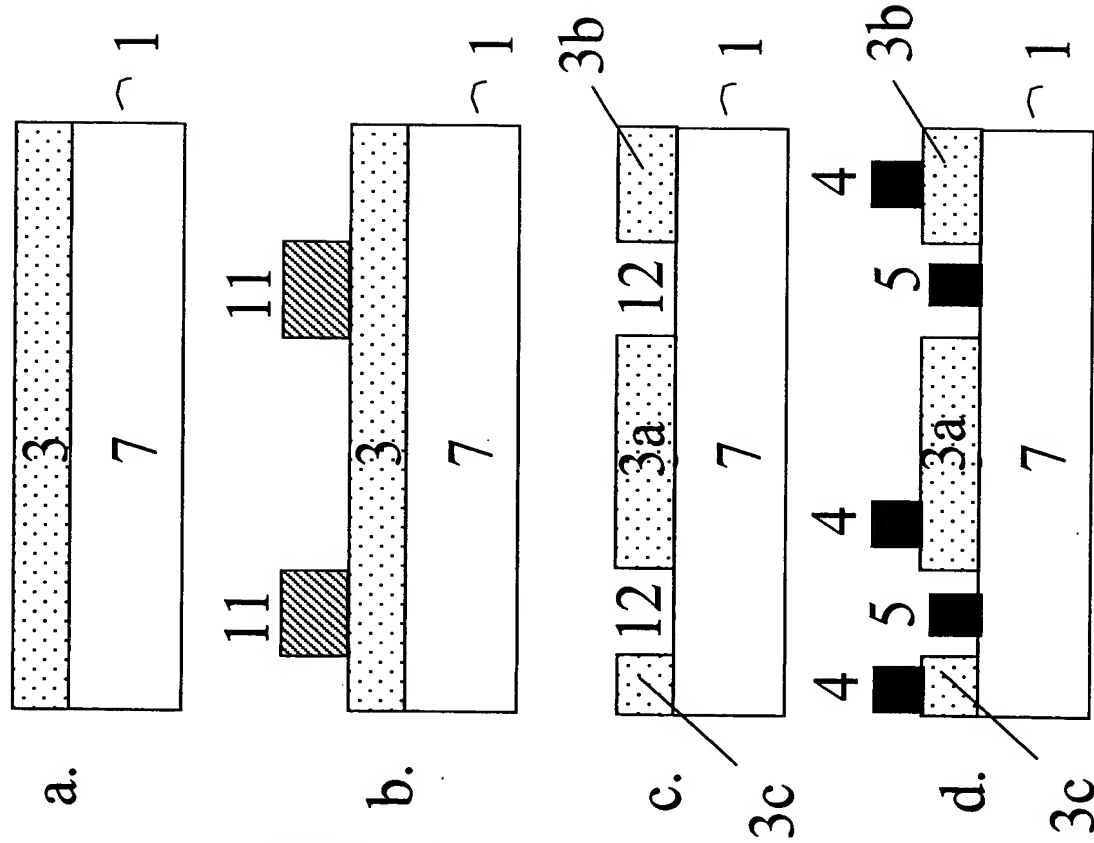


Figure 5:



SEMICONDUCTOR ETCHING PASTE AND THE USE THEREOF
 FOR LOCALIZED ETCHING OF SEMICONDUCTOR SUBSTRATES
 Szuycik, et al.
 Appl. No.: Unknown
 Atty Docket: IMEC306.001AUS